

INFORMATION DISCLOSURE CITATION <i>(Use several sheets if necessary)</i>				Docket Number (Optional) 11675.76	Application Number 09/627,649		
				Applicant(s) Sandhu, et al.			
				Filing Date July 28, 2000	Group Art Unit 2811 2814		
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
Tu	A	5,445,996	8/95	Kodera et al.	438	633	
Tu	B	5,486,493	1/96	Jeng	438	623	
Tu	C	5,399,235	3/95	Mutsaers et al.	438	633	
Tu	D	5,420,075	5/95	Homma et al.	438	624	
Tu	E	5,599,740	2/97	Jang et al.	438	626	
Tu	F	5,677,239	10/97	Isobe	438	633	
Tu	G	5,795,829	8/98	Shen	438	694	
Tu	H	5,708,303	1/98	Jeng	257	758	
FOREIGN PATENT DOCUMENTS							
REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
OTHER DOCUMENTS <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i>							
Tu	1	M.K. Jain et al., "Advanced Metalization and Interconnect Systems for ULSI Applications: Homogenous and Multilayer Low-K Interlevel Dielectric Architectures for Capacitance Reduction," Conference at University of California, Berkeley, California, October 1996.					
Tu		Tetsuya Homma, "Fluorinated SiO ₂ Films for Interlayer Dielectrics in Quarter-Micron ULSI Multilevel Interconnections," Mat Res Soc Symp Proc Vol 381 pp 239-248, 1995.					

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

11675.76

Application Number

09/627,649

Applicant(s)

Sandhu, et al.

Filing Date

July 28, 2000

Group Art Unit

2811

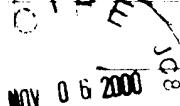
2814

*EXAMINER

INITIAL

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

J. Wary et al., "Vacuum-Deposited Parylene AF-4: A Thermally Stable, Low Dielectric Constant Polymer For Interlayer Dielectric Use," DUMIC Conference, pp. 207-213, February, 1996.



*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.